

Urbach tail studies by luminescence filtering in moderately doped bulk InP

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The shape of the photoluminescence line registered from a side edge of InP wafer is studied as function of the distance from the excitation spot. The observed red shift in the luminescence maximum is well described by radiation filtering and is consistent with the absorption spectra. Our method provides an independent and accurate determination of the Urbach tails in moderately doped semiconductors.

Studies of the optical absorption spectra near the interband absorption edge are widely used for characterization of semiconductor materials.^{1–3} The spectral dependence at low-energy absorption edge is well approximated by the Urbach exponential decay.⁴ However, the interband absorption usually overlaps with residual absorption by free carriers, masking the true dependence of the absorption tail. In doped samples, the absorption tail is additionally broadened and this effect is also masked by the residual electronic absorption.

Available theories^{5–8} do not provide description of the interband absorption tailing in the entire energy range from interband to deep tails. Still, they give an insight on the nature of the bandgap fluctuations causing the tailing. Tailing with Gaussian-like asymptotics is characteristic of classical potential fluctuations,⁵ whereas exponential decrease with square-root energy dependence in the exponent is indicative of quantum effects in the band tailing.^{6,7} Temperature variations of the tailing are accounted for by the adiabatic potential of thermally excited phonons.⁸

In a limited experimental range near the fundamental edge the observed absorption spectra may not differ noticeably from the Urbach law,⁷ but the temperature and the concentration dependence of the tailing parameters can be very informative. Therefore, accurate studies of the tailing dependence are highly desirable.

In this letter we describe an alternative experimental method for studying the semiconductor absorption edge by measuring the red shift of the peak of the luminescence line, registered from the side edge of the wafer. This shift is sensitive to the sample transparency at the peak wavelength, which is in the region where residual absorption dominates. We show that for moderately doped n -InP wafers this technique provides an accurate determination of the Urbach tailing energy.

We used 350 μm -thick InP wafers, doped n -type (S) in the range $n = 2 \times 10^{17}$ to $6 \times 10^{18} \text{ cm}^{-3}$ and measured the reflection and the transmission spectra to evaluate the absorption coefficient α .⁹ For all moderately doped samples, $n \leq 2 \times 10^{18} \text{ cm}^{-3}$, in the temperature range 78 to 320 K, the absorption edge exhibits an Urbach-type energy dependence in the range $\alpha = 10$ to 100 cm^{-1} . For lower doped samples, $n < 10^{18} \text{ cm}^{-3}$, the observed

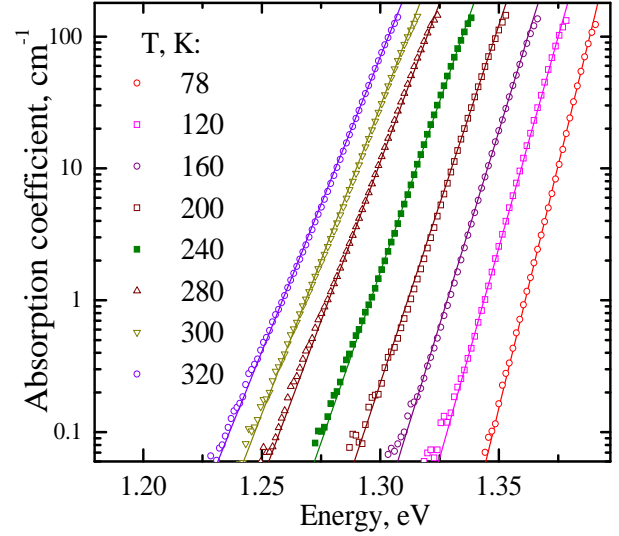


FIG. 1. (Color online) Absorption spectra of n -doped InP sample ($n = 3 \times 10^{17} \text{ cm}^{-3}$) at different temperatures (dots); the lines show fits to Eq. (1).

Urbach tail extends deeper into the band gap. One can recover the interband absorption in the bandgap by subtracting the residual (free-carrier) absorption which is essentially constant in this energy region. The resulting red-wing interband absorption spectra are presented in Fig. 1 for a sample with $n = 3 \times 10^{17} \text{ cm}^{-3}$ at several temperatures. The spectra clearly conform to the Urbach law,

$$\alpha = \alpha_0 \exp\left(-\frac{E - E_g}{\Delta(n, T)}\right), \quad (1)$$

where $\Delta(n, T)$ is the Urbach tail parameter and E_g is the bandgap energy. Matching the values of $E_g(T)$, well-known¹⁰ for undoped InP, gives $\alpha_0 = 1.1 \times 10^4 \text{ cm}^{-1}$; this value gives a good fit in a wide temperature range $T = 0$ to 1000 K.¹¹ The physical interpretation of α_0 as the value of α at $E = E_g$ (i.e. above the steep slope) suggests that it should not vary with the concentration at a moderate doping level, when the Fermi level is still below the conduction band edge. The experimentally observed temperature variations of $E_g(T)$ and $\Delta(n, T)$, are proportional to the population of thermally excited phonons and can be estimated^{11,12} using Einstein's model for the phonon spectrum. Variations of E_g with the dop-

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ing concentration reflect the effect of band-gap narrowing combined with Fermi energy shift due to filling of the impurity band,¹³ while the increase of Δ is attributed to the combined effect of the adiabatic random phonon potential and the random potential produced by concentration fluctuations.⁸

The luminescence spectra were registered from the side edge of the wafer for varying distances d between the excitation spot and the edge. The laser excitation energy was chosen close to the absorption edge to ensure large enough excitation volume.⁹ Luminescence spectra for a sample with $n = 3 \times 10^{17} \text{ cm}^{-3}$ are presented in Fig. 2 (a) for several values of d . Also shown (by a dashed line) is the luminescence emission spectrum, as observed in the reflection geometry.⁹ The red shift of the emission line maximum with increasing d is clearly seen.

Figure 2 (b) shows the absorption spectra⁹ for several doping levels in a broad energy range that includes the Urbach tail region. Two vertical dashed arrows indicate the range of the luminescence peak positions shown in Fig. 2 (a). Also depicted is the reflection luminescence spectrum on a logarithmic scale ($n = 3 \times 10^{17} \text{ cm}^{-3}$, $T = 300 \text{ K}$). It exhibits the exponential decay both in the red and the blue wings, and is well described by the van Roosbroek-Shockley quasi-equilibrium relation,¹⁴ viz. $S_0(E) = \alpha(E)E^2 \exp[-E/(kT_{\text{eff}})]$. Here T_{eff} is an effective temperature that can be estimated from the exponential slope at the blue wing of the spectrum.

Figure 3 shows the dependence of the luminescence peak position E_{max} on the distance d between the excitation spot and the wafer edge. The observed dependences $E_{\text{max}}(d)$ for several temperatures fit accurately to an expression of the form

$$E_{\text{max}}(d) = E_g - \Delta \ln[\alpha_0(d + d_{\text{min}})/a], \quad (2)$$

where Δ is the Urbach tail parameter and d_{min} is a small fitting parameter, $d_{\text{min}} \leq 0.17 \text{ mm}$ for all samples. The latter reflects details of the experimental geometry (finite width and depth of the excitation spot) and is of no importance for distances d in the range of 1 to 20 mm, i.e. for $d \gg d_{\text{min}}$. Taking the values of E_g from the observed dependence $\alpha(E)$, cf. Eq. (1), we find that the only remaining parameter is a . This parameter depends on the temperature and doping. Table I lists the obtained values of a for the sample with $n = 3 \times 10^{17} \text{ cm}^{-3}$ at several temperatures and also for $n = 2 \times 10^{18} \text{ cm}^{-3}$ at $T = 300 \text{ K}$.

Next we show that the observed $E_{\text{max}}(d)$, including the values of a , can be reproduced in a simple model that attributes the luminescent peak shift to wavelength-dependent filtering of outgoing radiation by the sample absorption. We assume that the position of the peak observed at distance d from the excitation spot is determined by the transparency $T(E, d)$ of InP wafer to the luminescence spectrum $S_0(E)$. In other words, the observed spectrum near its maximum should be described by the product $S(E, d) = S_0(E) \times T(E, d)$. The strong

TABLE I. Parameters of the luminescence spectra and the relation $E_{\text{max}}(d)$, Eqs. (2) and (6).

T, K	$E_g, \text{ eV}$	$\Delta, \text{ meV}$	$\Delta', \text{ meV}$	a	Δ/Δ'
160 ^a	1.397	7.4	13	0.58	0.57
200 ^a	1.386	7.9	14	0.54	0.56
300 ^a	1.355	9.4	15	0.63	0.63
300 ^b	1.361	10.6	16	0.68	0.67

^a $n = 3 \times 10^{17} \text{ cm}^{-3}$

^b $n = 2 \times 10^{18} \text{ cm}^{-3}$

refraction of outgoing radiation and a relatively small observation angle ensure a small and constant range of the angles of incidence. Therefore the d dependence of the transparency $T(E, d)$ reflects one-dimensional attenuation of light

$$T(E, d) = \exp[-\alpha(E)d]. \quad (3)$$

The outgoing spectra are not influenced by the surface reflection, but may be modified by multiple interband re-absorption of photons which leads to the creation of new minority carriers and new radiative emission events (photon recycling). However, if the distance d is much larger than the width of the minority carrier distribution in the source (including the broadening of this distribution by photon-assisted diffusion), then the spectrum near its peak is quite insensitive to these processes. The maximum of the transmitted spectrum at varying d can be found from $dS(E, d)/dE = 0$. Using (3), this equation can be rewritten in the form

$$\frac{d \ln [S_0(E)]}{dE} \Big|_{\text{max}} = d \times \frac{d\alpha(E)}{dE} \Big|_{\text{max}}. \quad (4)$$

To evaluate the left-hand side of Eq. (4), we use the experimental exponential dependence of the luminescence spectra in the red wing. These spectra may be modulated by some factor reflecting the wavelength dependence of the radiation escape probability, but this does not affect the red-wing exponential decay. The intrinsic emission spectrum should be closely similar to the luminescence spectrum measured with high-energy excitation in the reflection geometry, where the observed spectrum is not influenced by the diffusion and filtering effects.

The decay in the red wing below the band edge is of the form

$$S_0(E) = S_{0,g} \exp\left(-\frac{E - E_g}{\Delta'}\right), \quad (5)$$

where Δ' is another Urbach-like tailing parameter. The experimentally observed values of Δ' are listed in Table I. Using Eqs. (1, 5) to calculate the derivatives in Eq. (4), we find

$$E_{\text{max}}(d) = E_g - \Delta \ln \left[\frac{\Delta'}{\Delta} (\alpha_0 d) \right] \quad (6)$$

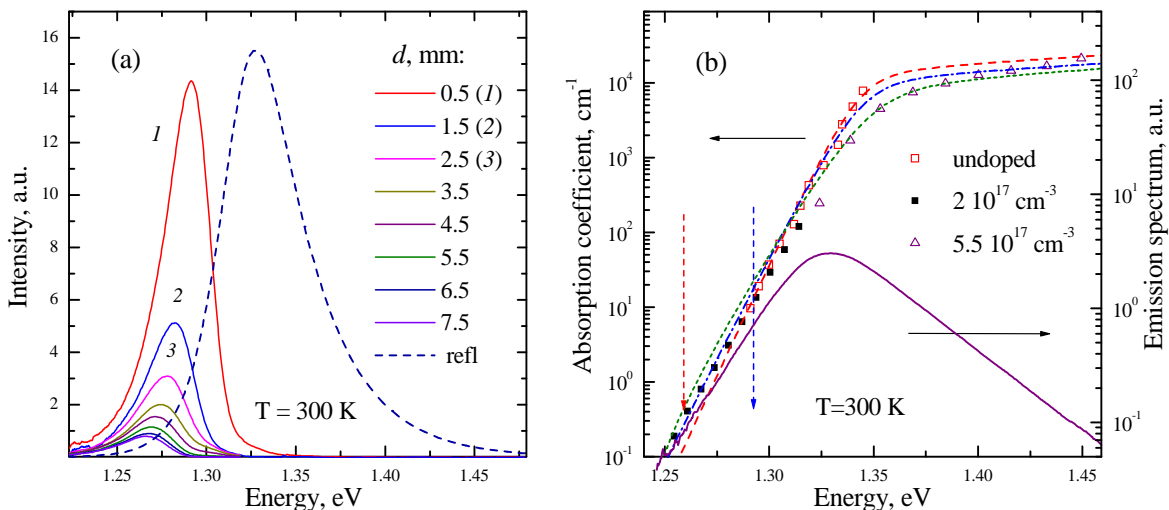


FIG. 2. (Color online) (a) Luminescence spectra for n -InP sample, $n = 3 \times 10^{17} \text{ cm}^{-3}$ at $T = 300 \text{ K}$ at different increasing distances d between the excitation spot and the wafer edge; the dashed line shows the emission spectrum measured in the reflection geometry⁹; (b) Reflection luminescence spectrum on a logarithmic scale together with the absorption spectra for several doping levels. Dashed arrows indicate the energy range of the variation in the luminescence spectral maximum

Comparing Eq. (6) with the empirical dependence (2) gives a physical interpretation to parameter a , viz. $a = \Delta/\Delta'$. As seen from the last two columns of Table I, this interpretation has excellent agreement with experiment for both samples and all temperatures.

For all studied cases, the values of Δ obtained from the slope of α and the slope of the dependence of E_{max} on $\ln(d)$ are very close, the difference never exceeding 0.2 meV. Thus, the described luminescence method provides

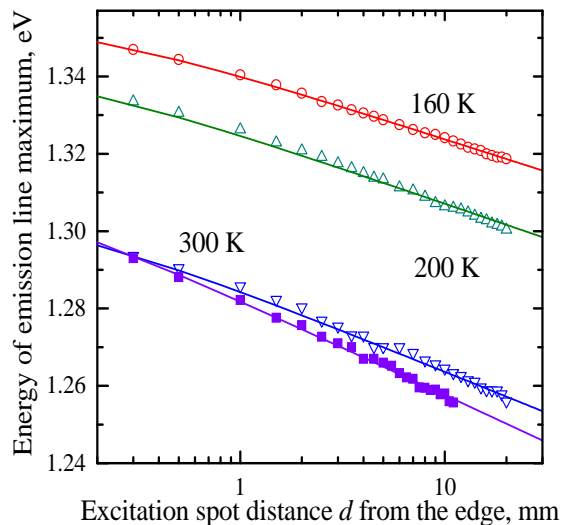


FIG. 3. (Color online) Experimentally observed shift of the luminescence peak with the distance d from the sample edge for two samples with $n = 3 \times 10^{17} \text{ cm}^{-3}$ (open dots) and $n = 2 \times 10^{18} \text{ cm}^{-3}$ (full dots); the lines show the dependence given by Eq. (2) with parameters listed in Table I.

an independent way of measuring the tailing parameters. This method can be indispensable (in fact, the only available) in the case when the residual absorption is strong.

In low-doped crystals the Urbach tail is known to be due to the electron-phonon interaction, which implies a certain temperature dependence^{4,11} of the tailing parameter Δ . The doping effects in moderately- and highly-doped crystals are more complicated. While Δ grows with doping,⁸ the absorption spectrum is at the same time blue-shifted by the Fermi energy of the majority carriers (the Moss-Burstein shift). The smearing of absorption is then modified by the temperature spread of the majority carrier energy distribution. E.g., in doped GaAs samples, the absorption edge is often described by non-Urbach exponential tails of Gaussian type or Halperin-Lax type.^{5,6} These are difficult to distinguish with traditional absorption studies because of the residual absorption. Our evaluation from the luminescence experiments is more accurate in the region of small α – allowing to study and identify different types of tailing.

Finally, we note that in moderately doped III-V semiconductors the high quantum radiative efficiency results in high photon recycling^{9,15} that gives rise to a photon-enhanced minority carrier transport and can broaden the initial hole distribution over an enlarged diffusion length.^{16,17} More accurate consideration¹⁸ shows that the recycling-induced carrier transport should be viewed as anomalous diffusion – due to the extremely long photon propagation in the transparency region at the red wing of the emission spectrum. In our experiments, this phenomenon manifests itself as strongly enhanced values of a in low-doped samples at $T = 78 \text{ K}$. The approach described in the present work is well suited to study these anomalous diffusion effects, as will be reported separately.

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- ¹R. Akimoto, M. Kobayashi, and T. Suzuki, "The Urbach tail of absorption and photoluminescence spectra in EuSe," *J. Phys.: Cond. Mat.* **8**, 105 (1996).
- ²S. Duman and B. Gürbalak, "Urbach tail and optical absorption in layered semiconductor $\text{TlGaSe}_{2(1-x)}\text{S}_{2x}$ single crystals," *Physica Scripta* **72**, 79 (2005).
- ³E. Shalaan and H. Schmitt, "Urbach tail of gadolinium trihydride films," *J. Matter. Sci.* **42**, 3255 (2007).
- ⁴F. Urbach, "The Long-Wavelength Edge of Photographic Sensitivity and of the Electronic Absorption of Solids," *Phys. Rev.* **92**, 1324 (1953).
- ⁵For a discussion see, e.g., B. I. Shklovskii and A. L. Efros, *Electronic properties of doped semiconductors*, (Springer, Heidelberg, 1984); further discussion can be found in A. N. Piktin and H. H. Hegazy, "Fundamental absorption edge of semiconductor alloys with the direct-gap energy-band structure," *Semiconductors* **43**, 1259 (2009).
- ⁶B. Halperin and M. Lax, "Impurity-Band Tails in the High-Density Limit. I. Minimum Counting Methods," *Phys. Rev.* **148**, 722 (1966).
- ⁷S. John, C. Soukoulis, M. H. Cohen, and E. N. Economou, "Theory of electron band tails and the Urbach Optical-Absorption Edge," *Phys. Rev. Lett.* **57**, 1777 (1986).
- ⁸C. W. Greeff and H. R. Glyde, "Anomalous Urbach tail in GaAs," *Phys. Rev.* **B 51**, 1778 (1995).
- ⁹O. Semyonov, A. V. Subashiev, Z. Chen, and S. Luryi, "Radiation efficiency of heavily doped bulk n-InP semiconductor," *J. Appl. Phys.* **108**, 013101 (2010), see also <http://arxiv.org/abs/1003.6095> .
- ¹⁰I. Vurgaftman, J. R. Meyer, and L. R. Ram-Mohan, "Band parameters for III-V compound semiconductors and their alloys," *J. Appl. Phys.* **89**, 5815 (2001).
- ¹¹M. Beaudoin, A. J. G. DeVries, S. R. Johnson, H. Laman, and T. Tiedje, "Optical absorption edge of semi-insulating GaAs and InP at high temperatures," *Appl. Phys. Lett.* **70**, 3540 (1997).
- ¹²S. Y. Chung, D. Y. Lin, Y. S. Huang, and K. K. Tiong, "Piezoreflectance study of InP near the absorption edge," *Semicond. Sci. Technol.* **11**, 1850 (1996).
- ¹³M. Bugajski and W. Lewandowski, "Concentration-dependent absorption and photoluminescence of n-InP," *J. Appl. Phys.* **57**, 521 (1985).
- ¹⁴W. van Roosbroek and W. Shockley, "Photon-Radiative Recombination of Electrons and Holes in Germanium," *Phys. Rev.* **94**, 1558 (1954); the relation is also sometimes referred to as the Kubo-Martin-Schwinger theorem, cf. R. Kubo, "Statistical-Mechanical Theory of Irreversible Processes. I. General Theory and Simple Applications to Magnetic and Conduction Problems," *J. Phys. Soc. Jpn.* **12**, 570 (1957); P. C. Martin and J. Schwinger, "Theory of Many-Particle Systems," *Phys. Rev.* **115**, 1342 (1959).
- ¹⁵G. B. Lush, "B-coefficient in n-type GaAs," *Solar Energy Materials and Solar Cells* **93**, 1225 (2009).
- ¹⁶P. Dumke, "Spontaneous Radiative Recombination in Semiconductors," *Phys. Rev.* **105**, 140 (1957).
- ¹⁷O. von Roos, "Influence of radiative recombination on the minority carrier transport in direct band-gap semiconductors," *J. Appl. Phys.* **54**, 1390 (1983).
- ¹⁸S. Luryi and A. Subashiev, "Semiconductor scintillator for 3-dimensional array of radiation detectors," in *Future Trends in Microelectronics: From Nanophotonics to Sensors to Energy*, edited by S. Luryi, J. M. Xu, and A. Zaslavsky (Wiley-Interscience, Hoboken, New Jersey, 2010), pp. 331-346, see also <http://www.ee.sunysb.edu/~serge/236.pdf> .